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United States Patent [19]

Fong et al.

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[54]	METHODS AND APPARATUS FOR PRESTABILIZED PLASMA GENERATION FOR MICROWAVE CLEAN APPLICATIONS
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[73] Assignee: Applied Materials, Inc., Santa Clara, Calif.

[21] Appl. No.: **08/746,658** [22] Filed: Nov. 13, 1996

[51] [52] 438/905

[58] **Field of Search** 315/111.21; 438/714, 438/727, 905; 134/1.1, 1.2

[56] References Cited

U.S. PATENT DOCUMENTS

4,576,692	3/1986	Fukura et al 204/165
4,579,623	4/1986	Suzuki et al 438/714 X
4,872,947	10/1989	Wang et al 156/643
4,951,601	8/1990	Maydan et al 118/719
5,082,517	1/1992	Moslehi 156/345
5,266,364	11/1993	Tamura et al 427/571

5,273,609	12/1993	Moslehi 315/111.21 X
5,282,899	2/1994	Balmashnov et al 118/723 R
5,403,434	4/1995	Moslehi 134/1.2
5,468,686	11/1995	Kawamoto 438/905 X
5,578,163	11/1996	Yachi 438/714 X

FOREIGN PATENT DOCUMENTS

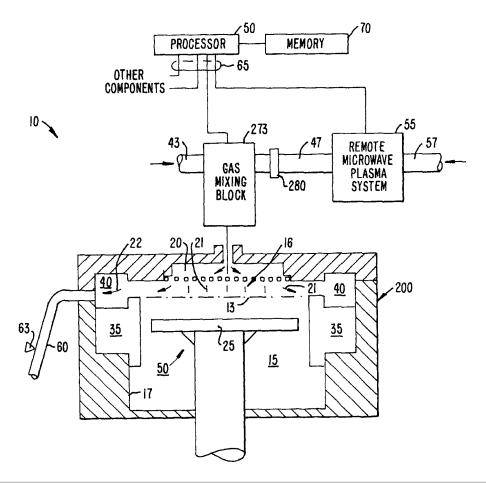
7/1992 Japan 315/111.21

Primary Examiner—Robert Pascal Assistant Examiner—Justin P. Bettendorf Attorney, Agent, or Firm—Townsend & Townsend & Crew

[57] **ABSTRACT**

The present invention provides systems, methods and apparatus for high temperature (at least about 500-800° C.) processing of semiconductor wafers. The systems, methods and apparatus of the present invention allow multiple process steps to be performed in situ in the same chamber to reduce total processing time and to ensure high quality processing for high aspect ratio devices. Performing multiple process steps in the same chamber also increases the control of the process parameters and reduces device damage. In particular, the present invention can provide high temperature deposition, heating and efficient cleaning for forming dielectric films having thickness uniformity, good gap fill capability, high density, low moisture, and other desired characteristics.

20 Claims, 42 Drawing Sheets





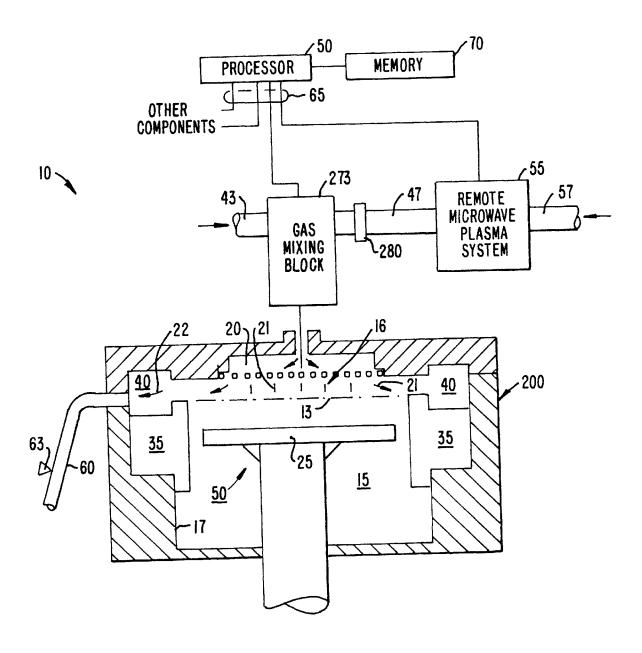


FIG. IA.



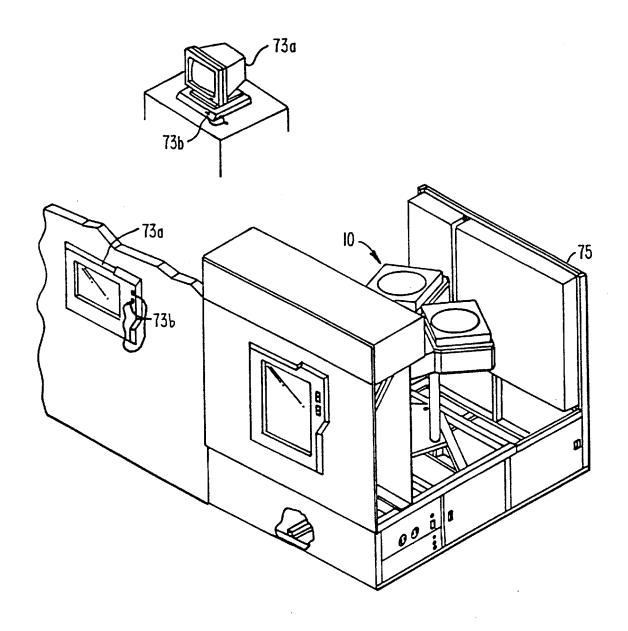
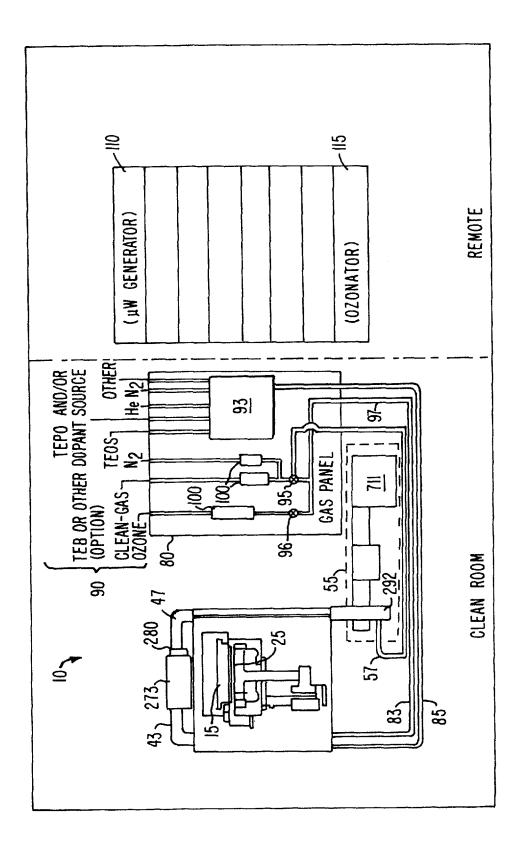
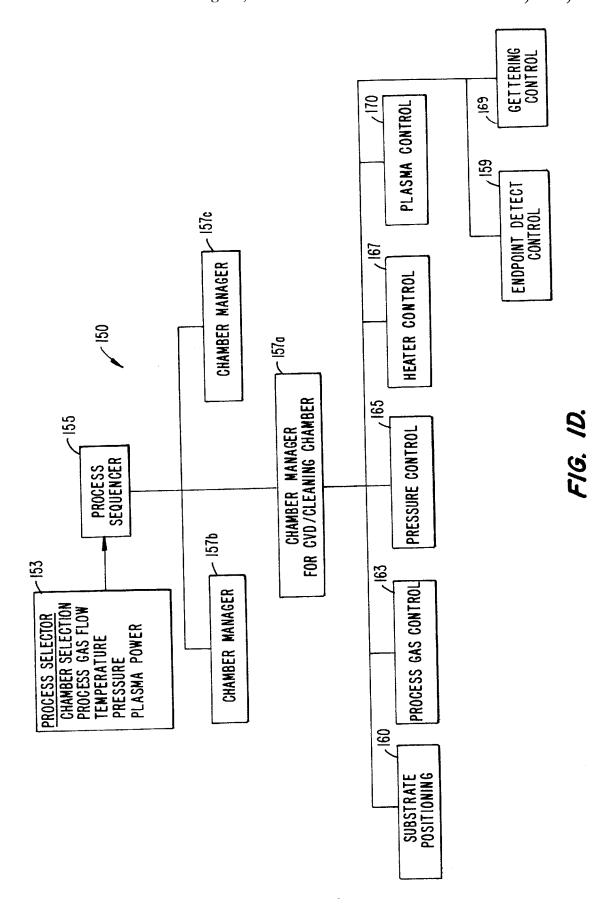


FIG. IB.







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